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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/707,407	12/11/2003	Abdelaziz Ikhlef	GEMS8081.201	1406
27061	7590 08/11/2006		EXAM	INER
ZIOLKOWSKI PATENT SOLUTIONS GROUP, SC (GEMS)			KAO, CHIH CHENG G	
	14135 NORTH CEDARBURG ROAD MEQUON, WI 53097		ART UNIT	PAPER NUMBER
			2882	
			DATE MAILED: 08/11/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
	10/707,407	IKHLEF ET AL.			
Office Action Summary	Examiner	Art Unit			
	Chih-Cheng Glen Kao	2882			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
A SHORTENED STATUTORY PERIOD FOR RETHE MAILING DATE OF THIS COMMUNICATION  - Extensions of time may be available under the provisions of 37 CFI after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, at a lift NO period for reply is specified above, the maximum statutory period for reply within the set or extended period for reply will, by standard patent term adjustment. See 37 CFR 1.704(b).	N. R 1.136(a). In no event, however, may a reply be ting. reply within the statutory minimum of thirty (30) day riod will apply and will expire SIX (6) MONTHS from ratute, cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 0	2 August 2006.				
2a) ☐ This action is <b>FINAL</b> . 2b) ☑ ¯	This action is non-final.				
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.				
Disposition of Claims					
<ul> <li>4)  Claim(s) 1-9,12-15 and 18-29 is/are pending in the application.</li> <li>4a) Of the above claim(s) is/are withdrawn from consideration.</li> <li>5)  Claim(s) 1-7,15,18-26,28 and 29 is/are allowed.</li> <li>6)  Claim(s) 8,9,12-14 and 27 is/are rejected.</li> <li>7)  Claim(s) is/are objected to.</li> <li>8)  Claim(s) are subject to restriction and/or election requirement.</li> </ul>					
Application Papers					
9) The specification is objected to by the Exam 10) The drawing(s) filed on 11 December 2003  Applicant may not request that any objection to  Replacement drawing sheet(s) including the con  11) The oath or declaration is objected to by the	is/are: a)⊠ accepted or b)□ object the drawing(s) be held in abeyance. Sec rrection is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119					
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No.</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>					
Attachment(s)	<b>—</b> ———————————————————————————————————				
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statement(s) (PTO-1449 or PTO/SE Paper No(s)/Mail Date</li> </ol>					

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#### **DETAILED ACTION**

#### Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on June 21, 2006, has been entered.

#### Claim Objections

2. Claims 8, 9, 12-14, and 27 are objected to because of the following informalities, which appear to be minor draft errors including grammatical and/or lack of antecedent basis problems.

In the following format (location of objection; suggestion for correction), the following correction(s) may obviate the objection(s): (claim 8, line 12; replacing "avoids" with - - avoiding--).

Claims 9, 12-14, and 27 are objected to by virtue of their dependency. For purposes of examination, the claims have been treated as such. Appropriate correction is required.

# Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person

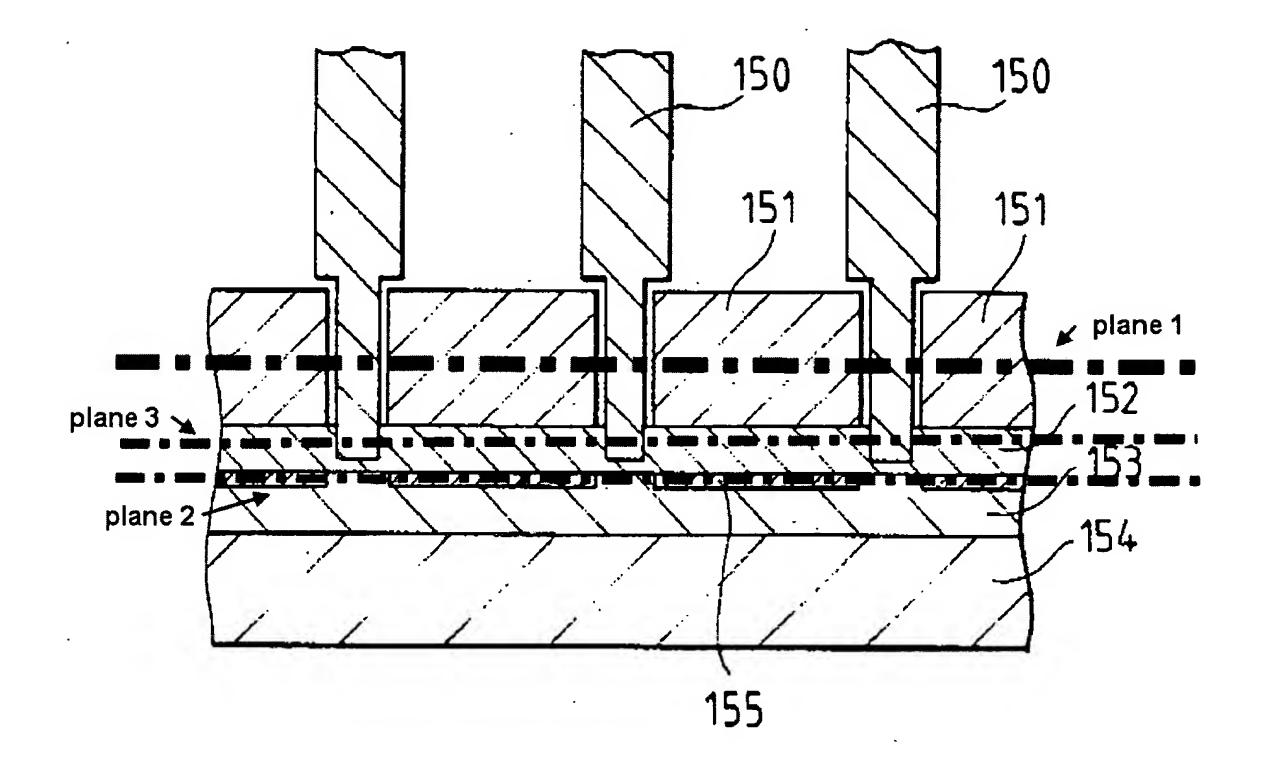
having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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- Claims 8, 9, 12-14, and 27 are rejected under 35 U.S.C. 103(a) as being unpatentable 3. over Fujii et al. (US 4982096) in view of Possin et al. (US 5430298).
- Regarding claim 8, Fujii et al. discloses an apparatus comprising a first scintillator and a 4. second scintillator (fig. 9, #151) positioned adjacently to one another and distanced from one another by a given width, a first photodiode operationally aligned to detect illumination of the first scintillator and a second photodiode operationally aligned to detect illumination of the second scintillator (fig. 9, #153 and 155), and at least one mask element (fig. 9, #150) disposed in a plane disposed between the first and the second scintillators (fig. 9, #151) and the first and the second photodiodes (fig. 9, #153 and 155) to reduce transference between the first scintillator and the second photodiode and the second scintillator and the first photodiode (col. 7, lines 18-25), the at least one mask element having a width (fig. 9, width of #150 above #151) that exceeds the given width separating the first and the second scintillators from one another (fig. 9, width between #151), the plane avoiding intersection with any of the first scintillator, the second scintillator, the first photodiode, or the second photodiode (as seen at "plane 3" in the modified figure below), the at least one mask element (fig. 9, #150) located closer to the first and the second scintillators (fig. 9, #151) than the first and the second photodiodes (fig. 9, #153 and 155).

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However, Fujii et al. fails to disclose optically absorbing material.

Possin et al. teaches optically absorbing material (col. 5, lines 26-42).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to include the apparatus of Fujii et al. with the material of Possin et al., since one would be motivated to make such a modification for lower cross-talk and lower noise (col. 2, lines 30-35) as shown by Possin et al.

5. Regarding claim 9, Fujii et al. further discloses wherein the first and the second scintillators are spaced from one another by a lateral gap (fig. 9, gap between #151).

6. Regarding claim 12, Fujii et al. further discloses wherein each scintillator (fig. 9, #151) is spaced from its corresponding photodiode by a vertical gap (fig. 9, gap between #151 and 155).

- 7. Regarding claim 13, Fujii et al. further discloses wherein each mask element has a thickness (fig. 9, thickness of #150 above #151) at least equal to a height of the vertical gap (fig. 9, height of gap between #151 and 155).
- 8. Regarding claim 14, Possin et al. further teaches wherein at least one mask element is fabricated of at least black polyamide (col. 5, lines 32-40).
- 9. Regarding claim 27, Fujii et al. further discloses wherein a portion of the mask element (fig. 9, #150) is disposed adjacent to the scintillator array (fig. 9, #151).

### Allowable Subject Matter

- 10. Claims 1-7, 15, 18-26, 28, and 29 are allowed. The following is a statement of reasons for the indication of allowable subject matter.
- 11. Regarding claim 1, prior art fails to disclose or fairly suggest a CT detector, including an optical mask arranged and extended in major part along a third plane parallel to first and second planes, and disposed between a scintillator array and a photodiode array without encroachment upon any of the first plane or the second plane, the optical mask configured to reduce optical transference between a scintillator and a neighboring photodiode, the optical mask located closer

to the scintillator array than the photodiode array, in combination with all the limitations in the claim. Claims 2-7 and 26 contain allowable subject matter by virtue of their dependency.

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Regarding claim 15, prior art fails to disclose or fairly suggest a CT system, including an 12.

array of optical cross-talk inhibitors formed of optically absorbent material and interstitially

layered between, without encroachment upon, a layer of an array of scintillators and a layer of an

array of photodiodes, the array of optical cross-talk inhibitors located closer to the layer of the

array of scintillators than the layer of the array of photodiodes, the array of optical cross-talk

inhibitors located in a layer that comprises a substantially same major orientation as the layer of

the array of scintillators and the layer of the array of photodiodes, in combination with all the

limitations in the claim. Claims 18, 19, and 28 contain allowable subject matter by virtue of their

dependency.

Regarding claim 20, prior art fails to disclose or fairly suggest a method of CT detector 13.

manufacture, including the step of arranging a cellular arrangement of scintillators, a cellular

arrangement of photodiodes, and an optical cross-talk mask in a multi-planar stack wherein each

of the cellular arrangements and the optical cross-talk mask are arranged orthogonal to a central

axis of x-ray incidence on the cellular arrangement of scintillators such that the optical cross-talk

mask is sandwiched between the cellular arrangement of scintillators and the cellular

arrangement of photodiodes, such that the optical cross-talk mask is located closer to the cellular

arrangement of scintillators than the cellular arrangement of photodiodes, and such that in the

multi-planar stack a plane of the cellular arrangement of scintillators, a plane of the cellular

arrangement of photodiodes, and a plane of the optical cross-talk mask comprise a substantially same major orientation, in combination with all the limitations in the claim. Claims 21-25 and 29 contain allowable subject matter by virtue of their dependency.

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## Response to Arguments

Applicant's arguments with respect to claims 8, 9, 12-14, and 27 have been considered 14. but are most in view of the new ground(s) of rejection. Applicant's arguments filed June 21, 2006, have been fully considered but they are not persuasive.

Regarding at least claim 8, applicant argues that for the reasons presented with reference to claim 1, claim 8 is believed to not be anticipated by nor obvious over Fujii et al. The examiner disagrees. In response to applicant's argument that the references fail to show certain features of applicant's invention, it is noted that the features upon which applicant relies (i.e., an optical mask arranged and extended in major part along a third plane parallel to the first and the second planes, and disposed between the scintillator array and the photodiode array without encroachment upon any of the first plane or the second plane) are not recited in the rejected claim(s). Although the claims are interpreted in light of the specification, limitations from the specification are not read into the claims.

In conclusion, applicant's arguments are not persuasive, and Fujii et al. still applies as prior art in the claim rejections above.

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Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Chih-Cheng Glen Kao whose telephone number is (571) 272-

2492. The examiner can normally be reached on M - F (9 am to 5 pm).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Ed Glick can be reached on (571) 272-2490. The fax phone number for the

organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

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like assistance from a USPTO Customer Service Representative or access to the automated

information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Chih-Cheng Glen Kao

Examiner

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